

Form PTO 1449 U.S. Department of Commerce Patent and Trademark Office Information Disclosure Statement by Applicant	ATTY. DOCKET NUMBER NITT.0194	SERIAL NUMBER To be Assigned 10782,997
	APPLICANT TSUCHIYA et al.	
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U.S. Patent Documents

Examiner Initial	DOCUMENT NUMBER	DATE	NAME	CLA SS	SUBC LASS	FILING DATE

Foreign Patent Documents

Examiner Initial	DOCUMENT NUMBER	FILING DATE	COUNTRY	CLASS	SUB- CLASS	TRANSLATION	
						YES	NO
ms	10-84170	8/11/97	Japan			Abstract	X

Other Documents (Including Author, Title, Date Pertinent Pages, Etc.)

ms	R. Bhat et al., "High-Performance 1.3 μm AlGaInAs/InP Strained Quantum Well Lasers Grown by Organometallic Chemical Vapor Deposition", Journal of Crystal Growth (1004), pp. 858-865
	P.J.A. Thijs et al., "High Performance Buried Heterostructure $\lambda=1.5 \mu\text{m}$ InGaAs/AlGaInAs Strained-Layer Quantum Well Laser Diodes", 10 th International Conference on Indium Phosphide and Related Materials (1996) ThA2-2, pp. 765-768
	Tawee Tanbun-Ek et al., "High Performance Buried Heterostructure 1.55 μm Wavelength AlGaInAs/InP Multiple Quantum Well Lasers Grown Entirely by NOVPE Technique", 10 th International Conference on Indium Phosphide and Related Materials (May 1998) ThP-48, pp. 702-705
ms	C. E. Zah et al., "High-Temperature Modulation Dynamics of 1.3 μm Al _x Ga _{1-x} As/InP Compressive-Strained Multiple-Quantum-Well Lasers", 14 th International Semiconductor Laser Conference (1994), TH 1.3, pp. 215-216
EXAMINER	DATE CONSIDERED 7/26/05

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